## NOVEL REACTIONS OF TRIFLUOROAMINE OXIDE WITH ORGANIC AND INORGANIC SUBSTRATES

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The chemistry of trifluoroamine oxide has remained largely ignored since its initial synthesis more than twenty years ago [1,2]. A review of the chemistry and physical characteristics of trifluoroamine oxide has recently been published [3], indicating that its reported chemistry has been largely limited to its Lewis base behavior and Lewis acid catalyzed addition reactions.

We find that trifluoroamine oxide reacts readily with, for example, a variety of amines to form the corresponding N-fluoro and N-nitroso derivatives in good yields. Oxidative fluorination of non-halogenated phosphines occurs under mild conditions to give  $R_3^{PF}_2$ , and treatment of phosphites with ONF3 yields three fluorinated products, i.e., RF,  $(RO)_2P(0)F$  and  $(RO)_3PF_2$ . A number of metals including Ga, Sn and Sb are rapidly converted to  $GaF_3$ ,  $SnF_4$  and  $SbF_5$ , while WF6 is obtained from the reaction between ONF3 and W(CO)6. The synthesis of many new or previously difficult to obtain materials has been achieved, and their physical and chemical characteristics, including stability and synthetic utility, are described.

<sup>1</sup> N. Bartlett, J. Passmore and E. J. Wells, <u>J. Chem. Soc. Chem. Commun.</u>, 213, (1966).

<sup>2</sup> W. B. Fox et al., J. Am. Chem. Soc., 88 2604, (1966).

<sup>3</sup> H. J. Emeléus, J. M. Shreeve and R. D. Verma, Adv. in Inorganic Chemistry 32 (1988).